## AMENDMENTS TO THE CLAIMS

1. (Currently amended) A semiconductor light-emitting element mounting member comprising:

a substrate; and

a <u>at least one</u> metal film formed on a surface of said substrate, formed from Ag, Al, or an alloy containing said metals, and functioning as <u>at least one of</u> an electrode layer for mounting at least one of a semiconductor light-emitting element and or a reflective layer for reflecting light from a semiconductor light-emitting element wherein:

the thickness of the at least one metal film is 0.5 - 3 µm;

crystal grains of said metal or alloy forming said at least one metal film have a particle diameter along a surface plane of said at least one metal film of no more than 0.5 µm;

said <u>a</u> surface of said metal film has a center-line average roughness Ra of no more than 0.1 µm;

an adhesion layer and a barrier layer are formed, in sequence, on said substrate, with said metal film being formed on said barrier layer;

the thickness of the adhesion layer is  $0.01-1.00 \mu m$ ; and the thickness of the barrier layer is  $0.01-1.50 \mu m$ .

## 2. (Canceled)

- 3. (Previously presented) The semiconductor light-emitting element mounting member according to claim 1 wherein said metal film is formed as an alloy of at least one of Ag and Al and other metal, a proportional content of said other metal being 0.001 10 percent by weight.
- 4. (Previously presented) The semiconductor light-emitting element mounting member according to claim 3 wherein said other metal is at least one type of metal selected from a group consisting of Cu, Mg, Si, Mn, Ti, and Cr.

Docket No.: 20239/0204318-US0

Reply to Final Office Action of July 23, 2009

5. (Canceled)

6. (Previously presented) The semiconductor light-emitting element mounting member according to claim 1 wherein said metal film is formed from Al alone or from an alloy of Al and other metal.

- 7. (Previously presented) The semiconductor light-emitting element mounting member according to claim 1 wherein a thermal expansion coefficient of said substrate is  $1 \times 10^{-6}$ /K.
- 8. (Previously presented) The semiconductor light-emitting element mounting member according to claim 1 wherein a thermal conductivity of said substrate is at least 80 W/mK.
- 9. (Previously presented) The semiconductor light-emitting element mounting member according to claim 1 wherein said semiconductor light-emitting element mounting member is a flat submount.
- 10. (Previously presented) A semiconductor light-emitting device, comprising: the semiconductor light-emitting element mounting member of claim 1; and a semiconductor light-emitting element mounted in said semiconductor light-emitting element mounting member.
- 11. (Previously presented) The semiconductor light-emitting device according to claim 10 wherein the output of said semiconductor light-emitting element is at least 1 W.
- 12. (Previously presented) The semiconductor light-emitting mounting member according to claim 1 wherein said substrate is an insulative ceramic.

Application No. 10/599,036 Amendment dated September 18, 2009 Reply to Final Office Action of July 23, 2009

13. (Previously presented) The semiconductor light-emitting mounting member according to claim 12 wherein the insulative ceramic is selected from a group consisting of AlN, Al<sub>2</sub>O<sub>3</sub>, SiC, Si<sub>3</sub>N<sub>4</sub>, BeO, BN, and insulative Si.

Docket No.: 20239/0204318-US0